Reactions of Molybdenum Tetrahydrido Complex with Halohydrosilanes

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The thermal reactions of $[MoH_4(dppe)_2]$ (1, $dppe = Ph_2PCH_2CH_2PPh_2$) with $RSiH_2X$ afford $[MoH_2X(dppe)_1]$ ($[Ph_2PCH_2CH_2P(Ph)C_6H_4-o]RXSi-P,P,Si\}$) ($[Ph_2PCH_2CH_2P(Ph)C_6H_4-o]RXSi-P,P,Si\}$) ($[R=Ph, X=Cl (5a); R=cyclo-C_6H_{11}, X=Cl (5b); and <math>[R=Ph, X=Br (6)]$) by activation of the Si-H bond of the silanes and the ortho C-H bond of the phenyl group in the dppe ligand. Reduction of the Si-Cl and Mo-Cl bonds in [Sa] with LiAlH4 leads to the formation of the original complex [R=R] as a result of unusual Si-C bond cleavage. Meanwhile, dehalogenative reduction of [R=R] using zinc metal gives the known compound $[MoH_3\{[Ph_2PCH_2CH_2P(Ph)C_6H_4-o]_2(Ph)Si-P,P,P,P,Si\}]$ ([R=R]). The experimental results reported herein provide certain evidence for the involvement of the silylene species in the unusual formation of the present polydentate phosphinoalkylsilyl ligands.

Transition-metal silyl complexes constitute a widely studied class of organometallic compounds.¹ Recently, we have reported that the thermal reaction of [MoH₄(dppe)₂] (1, dppe = Ph₂PCH₂CH₂PPh₂) with phenylsilane leads not only to oxidative addition of a Si–H bond to the metal center but also to activation of the ortho C–H bonds of the phenyl groups in the two dppe ligands to give a new class of molybdenum–silyl hydrido complex 2 with a novel pentadentate ligand comprised of a P–P–Si–P–P framework (Scheme 1).² We have found that this reaction is not limited to primary silanes. Even in the case of a secondary silane system, similar activation of the Si–H bond and the ortho C–H bond took place to give a hydrido complex 3 with a tridentate ligand comprised of a P–P–Si framework.

The most plausible pathway for these novel transformations seemed to involve orthometallation by dppe of 16-electron [MoH₂(dppe)₂] formed by H₂ loss, followed by oxidative addition of the silanes. ^{2c} However, significant insight into the mechanism of this unusual C–Si bond formation was obtained by investigation using deuterium-labeling, which suggests that the reaction path includes the intermediacy of a silylene metal complex via an α -migration of hydrogen as is mentioned in the latter part. ^{2d}

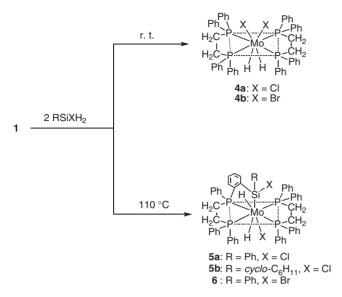
We have also demonstrated the high reactivity of the resulting complexes 2 and 3 toward various substances. To date, we have prepared and structurally characterized a number of new related compounds having these novel polydentate phosphinoalkyl–silyl ligands.³

We are particularly interested in exploring how variation of the substituents on the silane affects the formation of the products. Reported here are the results of studies extending this chemistry to halohydrosilanes. It has been established that activation of Si–H bonds in halohydrosilanes would be preferable to that of the Si–X (X = halogen) bond. However, there have been several reports of facile activation of the Si–X bonds. Thus, it is a moot point whether an oxidative addition of Si–H bond would take place or whether a Si–X bond cleavage would proceed.

Results and Discussion

Reaction of [MoH₄(dppe)₂] with Halohydrosilanes. The reactions of **1** with 2 equiv of RSiH₂X (R = Ph, *cyclo*-C₆H₁₁; X = Cl, Br) in toluene at ambient temperature afforded the known *cis*-[MoH₂X₂(dppe)₂] (**4a**, X = Cl; **4b**, X = Br)⁵ in moderate yields (ca. 50%). It is well-known that in the presence of halocarbons transition-metal hydrido complexes occasion-

Scheme 1.



Scheme 2.

ally undergo metathesis to give the corresponding halogeno compounds. 6 Indeed, 1H NMR study revealed that the reaction between 1 and CCl₄ produced 4a in a similar manner. Thus, in the case of RSiH₂X, the analogous conversion appeared to take place.

The increase of reaction temperature altered the reaction dramatically. At 110 °C, dihydrido complexes (R = Ph, X = Cl(5a); $R = cyclo\text{-}C_6H_{11}$, X = Cl (5b); and R = Ph, X = Br (6)) with a tridentate ligand ([Ph2PCH2CH2P(Ph)C6H4-0]RXSi-P.P.Si) comprised of the P-P-Si framework were isolated, according to Scheme 2. As expected, the activation of the Si-H bond in the halohydrosilanes and the ortho C-H bond of the phenyl group in the dppe ligand occurred. We have also confirmed that reaction of 4a with PhSiH2Cl at 110 °C does not give 5a. Consequently, the first step is the thermally induced formation of 16-electron [MoH₂(dppe)₂]. These results demonstrate that complex 1 displays a pronounced preference for Si-H oxidative addition over Si-X oxidative addition at elevated temperatures. In addition, just as in the foregoing reactions of the secondary silanes, the process would include the intermediacy of a silvlene metal complex via α -migration of hydrogen. Probably the resulting trihydrido complexes further react with the halohydrosilanes to produce the halogeno dihydrido compounds 5 and 6.

Complexes **5** and **6** have been characterized by IR, and ¹H and ³¹P NMR spectroscopies as well as by a preliminary X-ray crystal structure determinations (**5a** and **6**). ⁷ The NMR spectroscopic data for **5** and **6** illustrate that two complexes exhibit only slight differences in their chemical shifts and coupling patterns; these results are consistent with the X-ray analysis (vide infra).

The IR spectra of complexes **5** and **6** showed ν (Mo–H) at 1716–1718 cm⁻¹, which are at lower frequency than that of **3** by about 10 cm⁻¹. The ¹H NMR spectra of **5** and **6** consist of broad peaks arising from PCH₂CH₂P protons between 2.2 and 2.6 ppm and of broad multiplet signals corresponding to two hydrido protons at around -6 ppm, which are at higher field compared with **2** and **3**. The ³¹P{¹H} spectra of complexes **5**

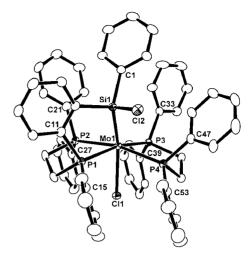


Figure 1. ORTEP drawing of 5a.

Table 1. Selected Interatomic Distances and Angles in 5a

Distances/Å			
Mo1-Cl1	2.5421(8)	Mo1-P1	2.4762(9)
Mo1-P2	2.5379(1)	Mo1-P3	2.4819(1)
Mo1-P4	2.5263(1)	Mo1-Si1	2.4744(1)
Cl2-Si1	2.159(2)	Si1-C1	1.904(3)
Si1–C8	1.894(3)		
Angles/°			
Cl1-Mo1-Si1	150.62(4)	P1-Mo1-P2	76.93(3)
P1-Mo1-P3	164.05(3)	P1-Mo1-P4	103.96(4)
P1-Mo1-Si1	74.01(3)	P2-Mo1-P3	96.03(4)
P2-Mo1-Si1	100.25(3)	P3-Mo1-P4	79.10(3)
P3-Mo1-Si1	121.67(3)	P4-Mo1-Si1	94.51(4)
C12-Si1-C8	97.92(2)		

and **6** show four multiplet resonances at around 84, 63, 59, and 45 ppm with a 1:1:1:1 peak area ratio. The results indicate the presence of four nonequivalent P nuclei in each complex.

Figure 1 shows an ORTEP drawing of 5a. Some pertinent bond distances and angles are collected in Table 1. The crystal structure unambiguously indicates that the compound contains a new bond between the silicon atom and the ortho carbon of the phenyl group in one of the dppe ligands. Complex 5a adopts a distorted, square antiprismatic geometry about the molybdenum center; the four phosphorus atoms occupy the equatorial coordination sites. Although the overall geometry of 5a is very similar to that observed for 3, the metric parameters differ from one another (vide infra). The chloro ligand is axially coordinated trans to the silyl group. The hydrido ligands are not located. However their presence is confirmed by means of ¹H NMR and IR spectroscopy. A conspicuous structural feature is that the Mo-Cl bond of 2.5421(8) Å in 5a is considerably longer than the value of 2.387 Å in 4a.5b Consequently, the differing trans influence of the hydrido versus silyl ligand is at least semiquantitatively observed. Although both hydrido and silvl groups are known to have good σ -donor ability which is closely concerned with the transinfluence,8 our results have clearly verified that the silyl group has a high trans-influence much greater than the hydrido ligand.

$$\begin{bmatrix} \text{MoH}_{4}(\text{dppe})_{2} \end{bmatrix} \xrightarrow{-H_{2}} & \begin{bmatrix} \text{MoH}_{2}(\text{dppe})_{2} \end{bmatrix} \xrightarrow{Ph \text{ Interpretation of the position of the position$$

Scheme 3.

The mean Mo–P bond distance at 2.5056 Å in **5a** is appreciably longer than that of 2.4645 Å in **3**. In contrast the Mo–Si bond length of 2.4744(1) Å in **5a** is significantly shorter than the value of 2.541(2) Å in **3**. This distance is also quite short when compared to the other Mo–Si distances of structurally characterized complexes derived from **2** and **3**, which range from 2.518 to 2.559 Å.³ Furthermore, the Si–Cl length of 2.159(2) Å in **5a** is considerably longer than the value of 2.079 Å found in Ph₃SiCl.⁹ These structural data for **5a** may be understood in terms of an interaction of the anti-bonding σ^* -orbital of silicon to chloride and the molybdenum d π orbital.^{1a}

As mentioned previously, on the basis of deuterium-labeling, we proposed that the reaction between 1 and phenylsilane occurs by the sequence of events shown in Scheme 3.2d The first step, the loss of H₂ upon thermolysis of 1 is well documented. 10 The silane addition product A would undergo further loss of H₂ to give a putative 16-electron intermediate **B** which rearranges to a hydrido(hydrosilylene) complex C via an overall 1,2-H shift. Recently, this type of transformation has been firmly established by Tobita et al. for group 6 transition-metal hydridos [Cp'(CO)₂(H)W=Si(H){C(SiMe₃)₃}] $(Cp' = Cp^* \text{ or } \eta^5 - C_5 Me_4 Et)$. Strong interactions between the silvlene and hydrido ligands have been shown to exist in these complexes, thus the driving force for the formation of C may be a similar interligand interaction. The following ortho C-H bond scission of a phenyl group in one of the dppe ligand would produce the presumed intermediate **D**. A similar process (activation of an intramolecular aromatic C-H bond by silylene complexes) has been observed in ruthenium systems. ¹² Since we could not detect the silvlene intermediate C spectroscopically it is assumed that the lifetime of this species might be so short that it would not exist in sufficient concentration to be observable in a ¹H NMR spectrum. We think that the present insertion process is very rapid and is promoted by steric acceleration due to easy access of the C-H bond to the active site. The sequence of processes would repeat to attach Si to the other dppe ligand affording the final product 2.

We have thought that complex **5a** provides a direct approach to verify the validity of the above assumptions. At first glance the intermediate **D** would appear to be accessible through reduction of **5a** with a hydride reagent. Alternatively, dehalogenation of **5a** would lead to the generation of the silylene

species **E**. Thus, further study of **5a** was directed toward understanding the reaction chemistry of the chloro substituents on the silyl group and the molybdenum center with the goal of obtaining the mechanistic insight.

Reduction of 5a with LiAlH₄ and Zinc. First we carried out reduction of **5a** with LiAlH₄ in THF at 67 °C (Scheme 4). Surprisingly, the ¹H NMR spectrum of the crude reaction mixture indicated the major species present to be the original complex **1** (40%). The reaction probably led first to reduction of the Cl groups and then to the Si–Mo and Si–Ph bond cleavage.

An activation of Si–C bonds is potentially important in the development of new processes in organosilicon chemistry, although cleavage of an Si–Ph bond has fewer precedents. ¹³ It is generally recognized that transition-metal silyl complexes are susceptible to nucleophilic attack at silicon. ^{1a} In some silyl complexes, LiAlH₄ can displace the silyl group as the corresponding silane by direct attack at silicon. ¹⁴ However, the cleavage of an alkyl–silicon bond has seldom been observed in these reductions. The formation of 1 is thus highly puzzling at present, and the mechanistic details will be clarified by further work.

Next we explored the dehalogenation reaction of **5a**. Stirring **5a** in THF with an excess of zinc metal at reflux temperature for 4 h resulted in the formation of a yellow-green solution, from which the anticipated product **2** was isolated as the only major product (27%). The formation of **2** can be rationalized according to Scheme 5. Complex **5a** would undergo a two-electron reduction by Zn metal to form a dianionic species. Subsequent elimination of two chloride anions would yield the silylene species **E** which then inserts into the ortho C–H bond of the phenyl group to give **2**.

Conclusion

The reactions of $[MoH_4(dppe)_2]$ (1) with $RSiH_2X$ were investigated. At ambient condition the reactions afford the known cis- $[MoH_2X_2(dppe)_2]$; thus, facile activation of the Si-X bonds takes place. On the other hand, the reactions in refluxing toluene lead to the isolation of $[MoH_2X(dppe)\{[Ph_2PCH_2-CH_2P(Ph)C_6H_4-o]RXSi-P,P,Si\}]$ ($R=Ph,\ X=Cl\ (5a);\ R=cyclo-C_6H_{11},\ X=Cl\ (5b);$ and $R=Ph,\ X=Br\ (6)$) with the tridentate phosphinoalkyl–silyl ligand. These reactions proceed

Scheme 4.

Scheme 5.

by a route entirely similar to those reported for complexes 2 and 3; that is, Si–H, C–H, Si–C, and H–H bond cleavage/ formation all occur in the same system. The existence in the resulting complexes of halide substituents seems to make them susceptible to further transformation. Reduction of 5a with LiAlH₄ unexpectedly leads to the formation of the parent complex 1, which would involve an unusual activation of Si–C bond. In contrast, dehalogenation of 5a using zinc metal gives complex 2. The experimental results reported herein provide certain evidence for the involvement of the silylene species in the unusual formation of the present polydentate phosphinoalkyl–silyl ligands. Further studies on these and other related reactions are in progress.

Experimental

General Procedures. All manipulations were performed using standard Schlenk techniques under purified argon. All reagents were purchased from commercial suppliers and used as received without further purification. All solvents were dried by standard methods and were stored under argon. Complex 1¹⁶ and RSiH₂X¹⁷ were synthesized according to procedures previously reported. All NMR spectra were recorded on a JEOL-JNM-270 spectrometer. ³¹P{¹H} NMR peak positions were referenced to external PPh₃.

Reactions of 1 with PhSiH₂X at Ambient Temperature. A solution of 1 (0.31 g, 0.35 mmol) and PhSiH₂Cl (100 μ L, 0.75 mmol) in benzene (35 mL) was stirred overnight, during which time the solution turned from yellow to orange. The reaction mixture was then allowed to stand for 12 h at 0 °C, whereupon precipitates of unreacted 1 separated. The supernatant solution was removed with a bridge filter. The volatiles were removed in vacuo and the residue thus obtained was washed with diethyl ether (8 mL \times 3). The resulting yellowish solid was dried under vacuum

to yield 0.27 g (81%) of **4a**. The spectroscopic properties of **4a** are consistent with those of *cis*-[MoH₂Cl₂(dppe)₂].⁵ Complex **4b** was prepared in a manner similar to that for **4a** in 85% yield.

Reactions of 1 with PhSiH2Cl at 110°C. A solution of 1 (0.28 g, 0.31 mmol) and PhSiH₂Cl (90 µL, 0.63 mmol) in toluene (30 mL) was heated with stirring at 110 °C for 3 h. The resulting solution was concentrated to a volume of 25 mL under reduced pressure. Hexane (3 mL) was then added, and the mixture was allowed to stand for 12 h at 0 °C, whereupon yellow precipitates separated. The product was collected by filtration, washed with hexane (10 mL × 3), and then dried in vacuo to give 5a (0.23 g, 69%). **5a**: IR data (KBr): ν (Mo–H) 1716 cm⁻¹. ¹H NMR $(270 \text{ MHz}, C_6D_6, \text{ ppm})$: 8.0–6.5 (m, aromatics), 2.6–2.2 (m, PCH_2), -5.80-6.35 (br m, 2H, MoH). ³¹P NMR (C₆D₆, ppm): 83.0 (ddd, 1P, $J_{pp} = 5$, 21, 121 Hz), 63.0 (ddd, 1P, $J_{pp} = 10$, 21, 116 Hz), 62.0 (ddd, 1P, $J_{pp} = 10$, 27, 121 Hz), 43.0 (ddd, 1P, $J_{pp} = 5, 27, 116 \text{ Hz}$). Anal. Calcd for $C_{58}H_{54}Cl_2MoP_4Si$: C, 65.11; H, 5.09%. Found: C, 64.33; H, 5.54%. Complex **5b** was prepared in a manner similar to that for 5a in 74% yield. 5b: IR data (KBr): ν (Mo–H) 1718 cm⁻¹. ¹H NMR (270 MHz, C₆D₆, ppm): 8.0–6.5 (m, aromatics), 2.6–2.2 (m, PC H_2), 2.0–1.2 (m, 11H, C₆ H_{11}), -5.80--6.75 (br m, 2H, MoH). ³¹P NMR (C₆D₆, ppm): 85.0 (ddd, 1P, $J_{pp} = 5$, 22, 118 Hz), 61.0 (ddd, 1P, $J_{pp} = 8$, 22, 115 Hz), 57.0 (ddd, 1P, $J_{pp} = 8$, 27, 118 Hz), 46.0 (ddd, 1P, $J_{pp} = 5$, 27, 115 Hz). Anal. Calcd for C₅₈H₆₀Cl₂MoP₄Si: C, 64.75; H, 5.62%. Found: C, 64.62; H, 5.96%.

Reactions of 1 with PhSiH₂Br at 110 °C. PhSiH₂Br ($110 \mu L$, 0.59 mmol) was added dropwise with stirring to a solution of 1 (0.27 g, 0.30 mmol) in toluene ($30 \, \text{mL}$) at $110 \, ^{\circ}\text{C}$. After stirring for 3 h the resulting solution was concentrated to a volume of $25 \, \text{mL}$ under reduced pressure. Hexane ($2 \, \text{mL}$) was then added, and the mixture was allowed to stand for $12 \, \text{h}$ at $0 \, ^{\circ}\text{C}$, whereupon yellow precipitates separated. The product was collected by filtration,

washed with hexane ($10\,\text{mL}\times3$), and then dried in vacuo to give **6** ($0.28\,\text{g}$, 80%). **6**: IR data (KBr): $\nu(\text{Mo-H})$ 1716 cm⁻¹.
¹H NMR ($270\,\text{MHz}$, C_6D_6 , ppm): 8.0–6.5 (m, aromatics), 2.6–2.2 (m, PC H_2), -6.25–-6.75 (br m, 2H, MoH).
³¹P NMR (C_6D_6 , ppm): 79.0 (ddd, 1P, $J_{\text{pp}}=5$, 22, 116 Hz), 56.0 (ddd, 1P, $J_{\text{pp}}=12$, 27, 116 Hz), 53.0 (ddd, 1P, $J_{\text{pp}}=12$, 22, 112 Hz), 44.0 (ddd, 1P, $J_{\text{pp}}=5$, 27, 112 Hz). At present, no sample suitable for combustion analysis is available.

Reduction of 5a with LiAlH4. A slurry of **5a** (0.15 g, 0.14 mmol) and LiAlH4 (0.029 g, 0.75 mmol) in THF (10 mL) was prepared at 0 °C and warmed to ambient temperature. The slurry was then allowed to reflux overnight. Subsequently the reaction mixture was cooled to ambient temperature and slowly hydrolyzed with water (1 mL), following which the solvent and volatiles were removed under vacuum. The resulting solid was extracted with benzene. After evaporation of the benzene, the residue was washed with hexane (5 mL \times 3) and dried under vacuum, yielding 0.05 g (40%) of **1**.

Reduction of 5a with Zinc. A slurry of **5a** (0.16 g, 0.16 mmol) and zinc powder (0.10 g, 1.6 mmol) in THF (15 mL) was allowed to reflux for 4 h. After removal of ca. 10% of the solvent in vacuo, hexane (5 mL) was added, and the mixture was allowed to stand for 12 h at 0 °C. The resulting mixture was filtered, and the filtrate was evaporated in vacuo. The residue was washed with hexane (5 mL \times 3) and dried under vacuum, yielding 0.04 g (27%) of **2**.

X-ray Crystallographic Analysis of 5a. Single crystals of **5a** suitable for X-ray analysis were obtained by slow recrystallization from toluene–hexane. The intensity data were collected on a Rigaku Saturn CCD area detector with graphite monochromated Mo Kα radiation ($\lambda = 0.71070\,\text{Å}$). The structure was solved by direct methods (SIR2002¹⁸) and expanded using Fourier techniques (DIRDIF99¹⁹). Some non-hydrogen atoms were refined anisotropically, while the rest were refined isotropically. Hydrogen atoms were refined using the riding model. Crystal data for **5** · C₇H₈ at $-160\,^{\circ}$ C: C₆₅H₆₀Cl₂MoP₄Si, MW = 1160.02, triclinic, space group $P\bar{1}$ (#2), Z = 2, $a = 12.7418(1)\,^{\circ}$ Å, $b = 13.4611(1)\,^{\circ}$ Å, $c = 20.5471(2)\,^{\circ}$ Å, $\alpha = 72.698(5)^{\circ}$, $\beta = 75.800(6)^{\circ}$, $\gamma = 62.325(4)^{\circ}$, $V = 2955.8(4)\,^{\circ}$ Å, $D_{\text{calcd}} = 1.303\,\text{g cm}^{-3}$, $2\theta_{\text{max}} = 55.0^{\circ}$, R1 ($I > 2\sigma(I)$) = 0.0520, wR2 ($I > 2\sigma(I)$) = 0.2062 for 10087 reflections and 718 parameters, GOF = 1.610.

Crystallographic data have been deposited with Cambridge Crystallographic Data Centre: Deposition number CCDC-750467. Copies of the data can be obtained free of charge via http://www.ccdc.cam.ac.uk/conts/retrieving.html (or from the Cambridge Crystallographic Data Centre, 12, Union Road, Cambridge, CB2 1EZ, UK; Fax: +44 1223 336033; e-mail: deposit@ccdc.cam.ac.uk).

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